УДК 531, 539.3, 539.5, 620.3

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# SIZE EFFECTS OF NANOHARDNESS IN SUPERIONIC CRYSTALS Cu<sub>6</sub>PS<sub>5</sub>I(Br)

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The mechanical properties of superionic crystals  $Cu_6PS_5I$  and  $Cu_6PS_5Br$  were studied by nanoindentation using the Continuous Stiffness Measurement (CSM) technique at room temperature. The investigations were carried out on  $Cu_6PS_5I$  and  $Cu_6PS_5Br$  single crystals grown by the vapor transport reaction method. The nanohardness (H) and Young's modulus (E) were measured using a Nano Indenter II (MTS Systems) equipped with a diamond Berkovich indenter in both pulse and harmonic load modulation modes. The parameters determined in the pulse mode were  $H = (3.41 \pm 0.03)$  GPa,  $E = (80.47 \pm 0.78)$  GPa for  $Cu_6PS_5Br$  and  $E = (3.71 \pm 0.08)$  GPa,  $E = (90.33 \pm 1.27)$  GPa for  $Cu_6PS_5I$ . A direct indentation size effect (ISE) was revealed, which was attributed to the development of plastic deformation and defect motion in the contact zone. The observed size effect was interpreted in the framework of the strain gradient plasticity (SGP) theory, which accounts for the formation of geometrically necessary dislocations beneath the indenter. The model parameters were determined as E = 4.52 GPa, E = 83 nm for E = 83 nm for E = 3.72 GPa, E = 93 nm for E = 3.72 GPa, E = 3.

**Keywords:** superionic crystals; hardness; Young's modulus; nanoindentation; strain gradient plasticity theory.

### Introduction

Crystals of  $Cu_6PS_5X$  (X = I, Br) belong to family of argyrodite-type superionic conductors [1], which are characterized by high ionic mobility at relatively low temperatures. Due to the combination of high ionic conductivity, structural stability, and chemical inertness, these materials are considered promising solid electrolytes for applications in solid-state supercapacitors, batteries, ion-selective membranes, and other electrochemical devices [2, 3]. In addition to their practical significance, Cu<sub>6</sub>PS<sub>5</sub>I(Br) crystals are model systems for fundamental studies of order-disorder processes, phase transitions, and structural relaxation in solids.

According to X-ray diffraction studies,  $Cu_6PS_5X$  (X = I, Br) crystals exhibit two phase transitions in the temperature range of 77–300 K. At room temperature,  $Cu_6PS_5I$  and  $Cu_6PS_5Br$  possess a cubic structure (space group  $F\overline{43}m$ ) [4,

5]. Upon cooling, two transitions occur: a ferroelastic one at  $Tc = (269 \pm 2) \text{ K}$  for  $Cu_6PS_5I$  and  $T_c = (268 \pm 2) \text{ K}$  for  $Cu_6PS_5Br$ , and a superionic transition at Ts = (165-175) K and  $T_s = (166-180) \text{ K}$ , respectively [5]. Below the ferroelastic transition temperature,  $Cu_6PS_5Br$  crystals belong to the monoclinic symmetry (Cc), while the superionic transition is isostructural in nature [6–9].

Superionic conductivity in  $Cu_6PS_5I(Br)$  compounds arises from the hopping diffusion mechanism of  $Cu^+$  ions between energetically equivalent vacant sites under the influence of an external electric field. A high vacancy concentration and a low activation energy for ion migration determine the unique physicochemical properties of these crystals, making them valuable for designing materials with controlled ion-transport characteristics.

One of the most effective methods for studying local physicomechanical properties of crystals is

nanoindentation, which provides information about hardness (H) and Young's modulus (E) within nanoscale volumes [10–14]. It is well known that at the nanoscale, these parameters can significantly differ from their macroscopic values due to the influence of defects, inhomogeneities, and structural fluctuations. Reducing the contact area of the indenter to less than 100 nm allows experimental H and E values to approach theoretical limits and reveals effects that are not observed in conventional mechanical testing.

Special attention in such studies is given to the indentation size effect (ISE) – the dependence of the measured hardness on the indentation depth [15-19]. This phenomenon is associated with the gradient of plastic deformation and the generation of geometrically necessary dislocations (GNDs) in the contact zone. Analysis of ISE within the framework of the strain gradient plasticity (SGP) theory makes it possible to identify the mechanisms of plastic deformation initiation, determine hardening parameters, and trace the relationship between microstructure, defect subsystem, and mechanical behavior of the material [17, 18, 20-22].

The investigation of indentation size effects in Cu<sub>6</sub>PS<sub>5</sub>I (Br) superionic crystals is important not only for understanding the fundamental regularities of deformation and relaxation processes in ion-conducting crystals but also for improving materials for solid-state energy applications. The obtained nanomechanical characteristics can assist in optimizing the composition and structure of these compounds to enhance the stability, mechanical strength, and durability of devices based on them.

The purpose of this work is to study the nanomechanical properties of Cu<sub>6</sub>PS<sub>5</sub>I and Cu<sub>6</sub>PS<sub>5</sub>Br single crystals by nanoindentation in harmonic and pulse loading modes, and to analyze the indentation size effect (ISE) within the framework of the strain gradient plasticity model.

#### 2. Materials and Methods

Samples and Surface Preparation.

Single crystals of Cu<sub>6</sub>PS<sub>5</sub>I and Cu<sub>6</sub>PS<sub>5</sub>Br were studied. To minimize the influence of surface roughness on the nanoindentation results, measurements were performed on the natural growth facets of the crystals. Prior to testing, the samples were cleaned in isopropanol and dried in an air stream. To avoid the overlap of plastic

deformation zones from adjacent indents, the spacing between indentation points was chosen to be at least  $10 \cdot a_{\text{max}}$ , where  $a_{\text{max}}$  is the maximum side length of the triangular indentation imprint. Equipment and Calibration.

Nanoindentation experiments were carried out using a Nano Indenter II (MTS Systems) equipped with a diamond Berkovich indenter (nominal apex angle equivalent to a semi-apex angle of  $\sim 65.27^{\circ}$ ). The system was operated under thermally stabilized conditions (295  $\pm$  2 K, relative humidity 30–50%) and was equipped with high-sensitivity load and displacement sensors.

Calibration. The contact area function  $A(h_c)$  was calibrated on a fused silica reference sample using the Oliver–Pharr method [23, 24], where hc is the contact depth. For an ideal Berkovich indenter,  $A(hc) \approx 24.5 \, h_c^2$ ; however, a polynomial correction was applied to account for the tip rounding coefficients determined from the reference sample. The system stiffness and drift error were also verified. The thermal drift was compensated by performing a pre-hold segment at a small load and/or a post-hold period after unloading.

Loading Schemes and Load–Depth (P–h) Diagrams.

Two complementary measurement protocols were applied.

- 1. Quasi-static P-h protocol (Oliver-Pharr method) [23].
- a) Loading to the maximum load  $P_{max}$  at a constant loading rate dP/dt or at a constant nominal strain rate dE/dt =  $(1/P)(dP/dt) \approx 0.05 \text{ s}^{-1}$ , where  $P_{max}$  is the peak load applied to the indenter.
- b) Holding at  $P_{max}$  for 10–1000 s to separate the contributions of viscous–plastic flow (creep) and structural relaxation.
- c) Unloading to 10% of  $P_{max}$  at the same dP/dt, followed by a short hold period (30–120 s) to assess drift, and then complete unloading to zero load

The result is a complete P(h) curve consisting of three segments: loading, hold, and unloading. In the unloading segment, the initial contact stiffness S = dP/dh at  $P \rightarrow P_{max}$  is determined and used in the Oliver–Pharr analysis to calculate hardness and elastic modulus.

2. Harmonic modulation (CSM-type) [25, 26]. In the Continuous Stiffness Measurement (CSM) protocol, a small harmonic (sinusoidal) load component is superimposed on the primary

loading signal during the indenter penetration. This allows real-time determination of the contact stiffness at each stage of loading and provides continuous numerical values of hardness (H) and Young's modulus (E) as a function of indentation depth. To obtain continuous H(h) and E(h) profiles during linearly increasing loading, a small oscillatory force component is added:

$$P(t)=P_0(t)+P_1\sin(\omega t),$$
 (1)

where  $P_0(t)$  increases linearly,  $P_1 \ll P_0$ , and the oscillation frequency  $\omega$  is chosen to avoid inertial artifacts. From the amplitude and phase response of the sample, the dynamic contact stiffness is determined, enabling the construction of H(h) and E(h) dependences without interrupting the loading cycle. This approach is particularly convenient for identifying and analyzing the indentation size effect (ISE) [14, 27].

For measuring the dependences H(h) and E(h), the following harmonic modulation parameters were used: the load P on the indenter was increased linearly from 0 to  $P_{max} = 40$  mN at a loading rate of 5 mN/s, while simultaneously applying a harmonic force component  $P_1$  with an amplitude of 0.2 mN and a frequency of 45 Hz. Thus, the resulting total load on the indenter can be expressed as:

$$P = \frac{dP}{dt} \cdot t + P_1 \cdot \sin(\omega t) \tag{2}$$

where  $dP_0/dt = 5 \text{ mN/s}$ ;  $\omega = 2\pi f$ ,  $P_1 = 0.2 \text{ mN}$ .

In this method, the main quantities were determined according to the standard procedure: Contact stiffness: S=dP/dh determined at the beginning of the unloading segment.

Contact depth:  $h_c = h_{max} - (\epsilon P_{max})/S$ , where  $\epsilon \approx 0.75$  for a Berkovich indenter (correction for elastic recovery of the indentation).

Contact area: A=A(h<sub>c</sub>) obtained from the calibrated area function.

Hardness:  $H=P_{max}/A(h_c)$ .

Reduced modulus: the reduced elastic modulus  $(E_r)$ , which describes the elastic interaction between the indenter and the specimen, is calculated as [23]:

$$E_r = \frac{\sqrt{\pi}}{2\beta} \cdot \frac{S}{\sqrt{A_c}} \tag{3}$$

where S = dP/dh is the contact stiffness,  $A_c$  is the projected contact area determined from the contact depth, and  $\beta$  is the geometric correction

factor of the indenter ( $\beta \approx 1.034$  for the Berkovich indenter).

$$E_S = \frac{1 - \nu_S^2}{\frac{1}{E_T} - \frac{1 - \nu_I^2}{E_I^2}} \tag{4}$$

Young's modulus of the specimen:

where  $E_r$  is the reduced modulus of the indenter–specimen system,  $E_i \approx 1140$  GPa is the Young's modulus of the diamond indenter,  $\nu_s$  is the Poisson's ratio of the specimen, and  $\nu_i \approx 0.07$  is the Poisson's ratio of the indenter.

Investigation of Viscoplastic Creep and Relaxation by the Quasi-Static Method

To separate the contributions of viscoplastic creep and structural relaxation, two types of holding segments were employed:

- under the peak load ( $P_{max}$ ): the indentation depth h(t) was recorded for 10–1000 s. The creep rate was evaluated as dh/dt in the quasi-stationary region of the h(t) curve.
- after unloading of the indenter: the decrease in indentation depth h(t) was recorded for 30–120 s and fitted using an exponential function to determine the characteristic relaxation times.

Analysis of the Indentation Size Effect (ISE) To analyze the ISE, hardness—depth curves H(h) were plotted and interpreted using the linearized form of the Nix—Gao model for Berkovich indentation [17]:

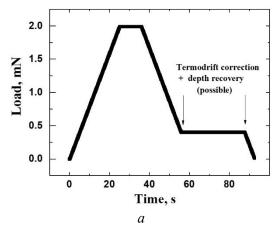
$$H^2 = H_0^2 \sqrt{1 + \frac{h^*}{h}} \tag{5}$$

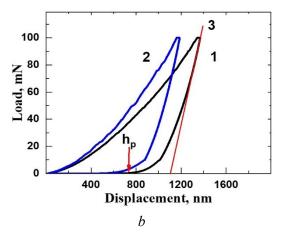
where  $H_0$  is the hardness at a depth free from strain-gradient effects, and  $h^*$  is the characteristic length associated with the density of geometrically necessary dislocations (GNDs). Within the range where the Nix-Gao law is valid, the "H²-1/h" dependence is linear. Linear approximation of the experimental H(h) data according to Eq. (5) yields the intercept on the H² axis corresponding to  $H_0^2$  ( $h \to \infty$ ), while the slope of the line provides the product  $H_0^2 \cdot h^*$ .

### 3. Results and Discussion

To determine the nanohardness of the crystals, a series of 20 indentation measurements was performed, each recording a complete P-h (load-displacement) curve. The residual indentation depth (h<sub>p</sub>) was determined from the curve and used to calculate the hardness. To evaluate Young's modulus, the initial portion of the unloading curve was analyzed, which

corresponds to a linear region representing the elastic recovery of the indentation. The Nano Indenter II software package enables automated determination of both hardness (H) and Young's modulus (E) from the load–displacement data.





**Fig. 1.** Load profile applied to the indenter (a) during the measurement of nanohardness and Young's modulus, and the corresponding P-h (load-displacement) curves (b) obtained for Cu<sub>6</sub>PS<sub>5</sub>Br (1) and Cu<sub>6</sub>PS<sub>5</sub>I (2) crystals with a holding time of 10 s at the peak load.

The averaged values of H and E for  $Cu_6PS_5Br$  and  $Cu_6PS_5I$  crystals along the (111) direction are as follows:  $E = (80.47 \pm 0.78)$  GPa,  $H = (3.41 \pm 0.03)$  GPa, and  $E = (90.33 \pm 1.27)$  GPa,  $H = (3.71 \pm 0.08)$  GPa, respectively. The mechanical characteristics of the crystals increase with the substitution of  $Br \rightarrow I$ , which correlates with the higher density and lattice parameter observed in the  $Cu_6PS_5Br \rightarrow Cu_6PS_5I$  series [5].

Figure 2 shows the dependences of hardness and Young's modulus of  $Cu_6PS_5Br$  and  $Cu_6PS_5I$  crystals on the penetration depth of the Berkovich indenter. These dependences were obtained in the CSM mode. In the region of h < 30 nm, the increase in E and H with increasing h may be associated with transient processes and the calibration conditions of the sharp indenter on the fused silica reference sample. The increase in E and H with increasing h is characteristic of hardness measurements performed using a spherical indenter.

The sharp Berkovich indenter used in this study possesses a finite tip radius – the so-called tip rounding radius. Therefore, at indentation depths h < 30 nm, the tip radius is comparable to the indentation depth, and the spherical geometry of the indenter makes a significant contribution to the measurement process. With increasing indentation depth (h > 30 nm), both E and H values for the studied crystals decrease over the entire range. This behavior may be attributed to the growth of deformation zones in the contact

region between the indenter and the sample, their propagation deeper into the crystal, and the motion and generation of defects within the near-surface region [10]. Such a variation of E(h) and H(h) can be interpreted as a direct indentation size effect (ISE) [15, 16].

The indentation size effect (ISE) observed in crystals arises from the strain gradient of plastic deformation induced in the nanocontact region during indentation. This phenomenon can be interpreted within the framework of the Strain Gradient Plasticity (SGP) theory [17, 18]. Analysis of the dependence of nanohardness on indentation depth makes it possible to establish the correspondence between experimental data and the gradient plasticity model and to determine the characteristic parameters of this model for the studied sample. In the framework of classical plasticity theory (without strain gradients), deformation is assumed to be homogeneous throughout the material volume. Plastic flow occurs through the motion of dislocations, but the theory does not account for how these dislocations are spatially distributed. During nanoindentation, the upper layer of the material is highly deformed, while the underlying layers experience much smaller strains. Consequently, at the micro- and nanoscale, the deformation becomes nonuniform, producing a plastic strain gradient. This gradient cannot be accommodated solely by the motion of "conventional" (preexisting or statistically stored) dislocations.

Therefore, the material necessarily generates additional dislocations to accommodate this nonuniform deformation. These additional dislocations are known as geometrically necessary dislocations (GNDs) – they do not arise from external stress but rather from deformation incompatibility within the crystal. In other words, GNDs form to "accommodate" regions of the crystal that deform differently, ensuring lattice continuity across these zones. The SGP theory accounts for the fact that the density of GNDs is proportional to the gradient of plastic strain [18].

$$\rho_{GND} \sim \frac{d\varepsilon_p}{dx} \tag{6}$$

This means that the larger the spatial gradient of plastic deformation, the greater the number of GNDs generated and, consequently, the higher the resistance to further deformation of the material beneath the indenter—that is, the material becomes harder.

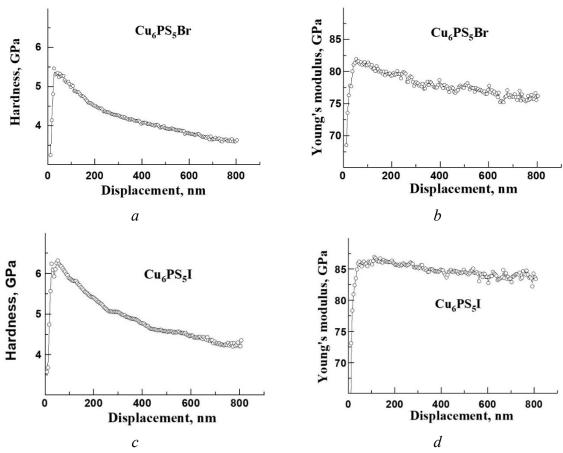


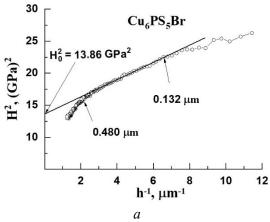
Fig. 2. Depth Dependence of Hardness and Young' modulus of single crystals Cu<sub>6</sub>PS<sub>5</sub>Br and Cu<sub>6</sub>PS<sub>5</sub>I.

As seen from Fig. 2, during nanoindentation an increase in hardness with decreasing indentation depth is observed in the region h > 30 nm. This behavior is explained by the formation of geometrically necessary dislocations (GNDs). When the contact area decreases, a strong gradient of plastic strain arises, leading to the generation of numerous GNDs, which increase the resistance to deformation and result in higher hardness. Thus, the indentation size effect (ISE) directly follows

from the presence of GNDs in the contact zone between the indenter and the sample. These GNDs are responsible for material hardening at the micro- and nanoscale levels. Plastic deformation beneath the indenter occurs through dislocation motion along hemispherical slip surfaces centered at the indenter tip. Under this deformation mechanism, as the indentation size increases, the density of GNDs decreases, and dislocation movement occurs along larger slip loops. According to the SGP theory, indentation

of crystals is accompanied by the formation of circular loops of geometrically necessary dislocations with Burgers vectors perpendicular to the specimen surface [17, 18]. According to Eq.

(5), H<sup>2</sup> should vary linearly with  $h^{-1}$ . Figure 3 presents the H(h) dependences plotted in H<sup>2</sup> – h<sup>-1</sup> coordinates for Cu<sub>6</sub>PS<sub>5</sub>Br (I) crystals.



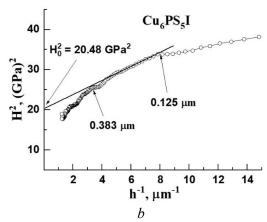
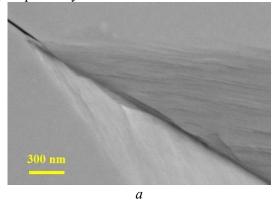


Fig 3. The size effects approximation of H(h) dependence of Cu<sub>6</sub>PS<sub>5</sub>Br and Cu<sub>6</sub>PS<sub>5</sub>I single crystals in the model SGP. Show the H(h) dependence in " $\left(\frac{H^2}{H_0^2}\right)$  -  $h^{-1}$ " coordinates. (line is result of a linear approximation)

The figures show that the dependences H(h) are well approximated by a straight line according to Eq. (5), with the fitting parameters  $H_0 = 4.52$  GPa and  $h^* = 83$  nm for  $Cu_6PS_5I$ , and  $H_0 = 3.72$  GPa and  $h^* = 93$  nm for  $Cu_6PS_5Br$ . The parameter ( $H_0$ )<sup>2</sup> is determined as the intersection point of the linear region of the  $H^2 = f(h^{-1})$  dependence with the ordinate axis, while  $h_*$  is obtained from the slope of this dependence relative to the abscissa axis. As seen from Fig. 3, the linear regions of  $H^2 = f(h^{-1})$  for  $Cu_6PS_5I$  and  $Cu_6PS_5Br$  crystals are observed in the indentation depth intervals of 125 - 383 nm and 132 - 480 nm, respectively. It can be assumed that within

these h intervals, a pure dislocation-controlled plastic deformation mechanism is realized, which is described by the SGP theory. At smaller indentation depths (h), deformation beneath the indenter exhibits an elasto-plastic character, while at larger depths, creep processes and crack formation may occur, indicating that the mechanical stress beneath the indenter exceeds the crystal's strength limit. Such cracks are visible in the SEM images of the indentation imprints, whereas traces of dislocation-mediated plastic deformation appear as slip bands and layer separations within the indented regions (Fig. 4).



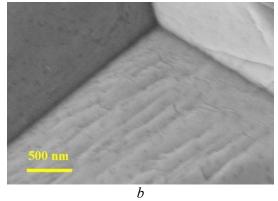
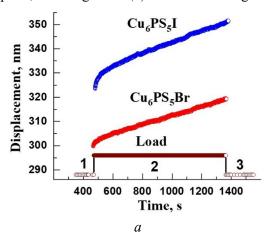


Fig. 4. SEM images of Berkovich indenter imprints on Cu<sub>6</sub>PS<sub>5</sub>I (a) and Cu<sub>6</sub>PS<sub>5</sub>Br (b) crystals at a loading force of 50 mN.

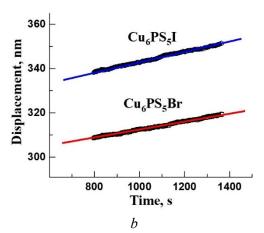
Figure 5 presents the results of studies of Cu<sub>6</sub>PS<sub>5</sub>I and Cu<sub>6</sub>PS<sub>5</sub>Br crystals performed in the

pulsed loading mode with a holding time of 900 s under load. In these measurements, the quasi-

static P-h protocol (Oliver-Pharr method) was applied, resulting in a P(h) curve consisting of



three characteristic segments: loading (1), holding (2), and unloading (3).



**Fig. 5.** Change in indentation depth during long-term holding under maximum load (a) and time-dependent change of indentation depth in the creep region (b).

The theory of elastic interaction between a rigid indenter and the plastic imprint formed at each stage of deformation is described in [28, 29]. It has been shown that the penetration of the indenter is accompanied by elastic-plastic deformation of the material beneath the indenter and in the adjacent regions. During the formation of the indentation imprint, several deformation zones are created within the contact region, which give rise to the elastic, plastic, and relaxation components of the overall deformation of the tested sample [11, 12]. The distribution of strain beneath the indenter is complex, and the total indentation depth can be expressed as the sum of with contributions associated different deformation mechanisms of the material under the indenter [12]:

h = h<sub>e</sub> + h<sub>r</sub> + h<sub>p</sub> (7) where  $h_e$  is the elastic component,  $h_e = P/k$ , with k being the stiffness of the material beneath the indenter and P the applied load;  $h_r$  is the relaxation (recoverable) component,  $h_r = h_{r0} + h_0 \exp(-\frac{t}{\tau})$ , t – where t is the loading time, (h<sub>ro</sub>=h<sub>r</sub> πρи  $t \rightarrow \infty$ ),  $\tau$  is the relaxation time, h<sub>p</sub> is the plastic component;  $h_p = \frac{\Delta h_p}{\Delta t} \cdot t$ ,  $\frac{\Delta h_p}{\Delta t}$  is the viscous flow rate (creep rate).

Under a sharp indenter, several deformation zones are formed in the sample: a hydrostatic zone, a gradient zone, an elasto-

plastic zone, and an elastic zone [11]. As the applied load (P) and indentation depth (h) increase, these zones extend deeper into the material, and their volumes expand. The relative contribution of each mechanism to the overall indentation process changes with load, leading to variations in the hardness and elastic modulus of the crystal. At smaller contact areas (under low loads), the contribution of the elastic component of deformation becomes more significant. The increase in E and H with decreasing h in the nanoregion (ISE) can be explained by the approach of the  $\sigma/E$  ratio to the theoretical strength limit of an ideal crystal lattice ( $\sigma \approx 0.1E$ , where  $\sigma$  is the mechanical stress [11]).

From Fig. 5, it can be seen that under constant loading, the indentation depth in the crystals increases, indicating the occurrence of creep and relaxation processes. To determine the creep rate and relaxation time, the h(t) dependences in the interval of 500–1400 s (Fig. 5) were approximated by linear functions:

h(t) =  $(h_0 + A_0 e^{-\frac{t}{\tau}}) + (k \cdot t + b)$  (8) where k is the plastic deformation rate and  $\tau$  is the relaxation time. The first term describes the relaxation process, while the second corresponds to the steady-state plastic deformation rate. The obtained plastic deformation rates k for Cu<sub>6</sub>PS<sub>5</sub>I and Cu<sub>6</sub>PS<sub>5</sub>Br r crystals were 0.022 nm/s and 0.018 nm/s, respectively.

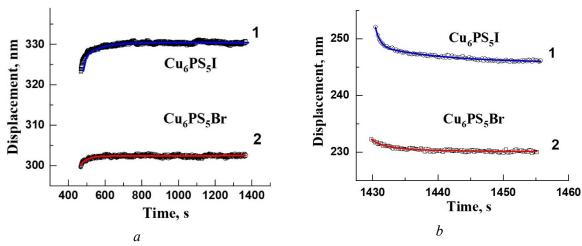


Fig. 6. Variation of indentation depth during the loading stage (a) and unloading stage (b).

To isolate the relaxation component  $h_r$ , the measured h(t) values were subtracted from the approximated linear dependence (h<sub>e</sub> = k·t + b). The corresponding relaxation components h<sub>r</sub>(t) are shown in Fig. 6a. These curves were fitted with exponential functions h<sub>r</sub>(t), from which the relaxation times ( $\tau$ ) for Cu<sub>6</sub>PS<sub>5</sub>I and Cu<sub>6</sub>PS<sub>5</sub>Br crystals were determined (see Table).

The study of the h(t) dependences after unloading of the indenter showed that, upon load removal, the indentation depth did not fully recover, indicating that the deformation of the materials contains not only plastic and elastic components but also a relaxation component. The h(t) dependence in this time interval was approximated using the corresponding exponential expression, and the results of the approximation are presented in Fig. 6b.

$$h(t) = h_0 - A_0 e^{-\frac{t}{\tau}}$$
 (9)

As seen from Table 1 and Fig. 6, a significant difference is observed between the Cu<sub>6</sub>PS<sub>5</sub>I and Cu<sub>6</sub>PS<sub>5</sub>Br crystals: the relaxation amplitude in Cu<sub>6</sub>PS<sub>5</sub>I is more than twice that in Cu<sub>6</sub>PS<sub>5</sub>Br, and the characteristic relaxation time is noticeably longer. This indicates a stronger and slower time-dependent response of the Cu<sub>6</sub>PS<sub>5</sub>I crystal under constant indentation load, whereas Cu<sub>6</sub>PS<sub>5</sub>Br reaches equilibrium more rapidly. Such

behavior is determined by the structural and ion-transport characteristics of these crystals. In  $Cu_6PS_5I$ , the lattice parameter (a = 9.7809(6) Å) and the ionic radius of the anion  $I^-$  (R = 2.20 Å) are larger compared to those of  $Cu_6PS_5Br$  (a = 9.7236(6) Å,  $Br^-$ : R = 1.96 Å) [30].

This promotes increased disordering of the Cu<sup>+</sup> cation sublattice and enhances ion mobility, which activates diffusion and anelastic relaxation mechanisms. In contrast, the smaller Br<sup>-</sup> anions in Cu<sub>6</sub>PS<sub>5</sub>Br form a more rigid framework that limits the rearrangement of the Cu<sup>+</sup> sublattice, leading to lower relaxation amplitudes and shorter relaxation times.

The recovery of the indentation imprint in Cu<sub>6</sub>PS<sub>5</sub>Br after unloading also occurs faster and within a smaller depth range, indicating a stiffer lattice and reduced Cu<sup>+</sup> ion mobility. The observed h(t) behavior after unloading confirms that the deformation response of superionic crystals contains not only an elastic component but also a significant time-dependent one, associated with ionic relaxation and diffusion processes within the  $Cu^+$ sublattice. post-effect prolonged (anelastic recovery) observed in Cu<sub>6</sub>PS<sub>5</sub>I indicates a redistribution of Cu<sup>+</sup> ions within the field of residual stresses and a gradual stabilization of the local structure following indentation.

**Table 1.** Mechanical parameters of the crystals obtained from nanoindentation measurements.

Composi-	H, GPa	E, GPa	k, nm/s	H <sub>0</sub> , GPa	h*, nm	$\tau_1$ , s	h <sub>0</sub> , nm	$\tau_2$ , s
tion								
Cu <sub>6</sub> PS <sub>5</sub> I	$3.71 \pm 0.08$	$90.33 \pm 1.27$	0.022	4,52	83	65	7.5	4,4
Cu <sub>6</sub> PS <sub>5</sub> Br	$3.41 \pm 0.03$	$80.47 \pm 0.78$	0.018	3,72	93	38	2.7	3,6

Within the framework of the strain gradient plasticity (SGP) model, the Cu<sub>6</sub>PS<sub>5</sub>I crystal exhibits higher hardness at shallow indentation depths and a smaller characteristic length h\*, indicating more intense hardening associated with the formation of geometrically necessary dislocations (GNDs). The combination of enhanced Cu<sup>+</sup> ion mobility and localized stresses leads to the formation of a complex stress-strain zone beneath the indenter, the relaxation of which proceeds more slowly due to the gradual rearrangement of ionic positions. The more flexible anionic sublattice in Cu<sub>6</sub>PS<sub>5</sub>I also contributes to longer-lasting anelastic and ferroelastic processes, thereby increasing both the amplitude and the duration of relaxation.

Thus, the larger  $h_0$  and  $\tau$  values (Table) characteristic of  $Cu_6PS_5I$  reflect its higher structural and ionic mobility compared to  $Cu_6PS_5Br$ . This feature must be taken into account when employing such materials in solid-state electrochemical devices, where prolonged relaxation processes may influence the stability of contact interfaces and the long-term mechanical reliability of the system.

## 4. Conclusions

The nanomechanical properties of Cu<sub>6</sub>PS<sub>5</sub>I and Cu<sub>6</sub>PS<sub>5</sub>Br superionic single crystals were investigated using the nanoindentation method in the Continuous Stiffness Measurement (CSM) mode. It was established that the hardness and Young's modulus are H = 3.71 GPa, E = 90.3 GPa for  $Cu_6PS_5I$  and H = 3.41 GPa, E = 80.5 GPa for Cu<sub>6</sub>PS<sub>5</sub>Br, respectively. A direct indentation size effect (ISE) was revealed and interpreted within the framework of the strain gradient plasticity (SGP) model. The model parameters were determined as  $H_0 = 4.52$  GPa,  $h^* = 83$  nm for  $Cu_6PS_5I$  and  $H_0 = 3.72$  GPa,  $h_* = 93$  nm for Cu<sub>6</sub>PS<sub>5</sub>Br, indicating stronger hardening of the iodide crystal at shallow indentation depths. Under constant load holding, relaxation processes and viscoplastic creep were observed. For Cu<sub>6</sub>PS<sub>5</sub>I, the relaxation amplitude is more than twice that of Cu<sub>6</sub>PS<sub>5</sub>Br, and the relaxation time is significantly longer ( $\tau = 64$  s versus 29 s), indicating a stronger and slower time-dependent response in the iodide crystal, associated with higher Cu<sup>+</sup> ion mobility and a more flexible anionic sublattice. The analysis of h(t) behavior after unloading revealed incomplete recovery of

the indentation imprint and a pronounced anelastic deformation component. In Cu<sub>6</sub>PS<sub>5</sub>I crystals, a prolonged post-effect was observed, caused by the redistribution of Cu<sup>+</sup> ions in the field of residual stresses and gradual stabilization of the local structure. In contrast, the recovery in Cu<sub>6</sub>PS<sub>5</sub>Br occurs faster, reflecting a stiffer lattice and lower ionic mobility.

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Стаття надійшла до редакції: 30.10.2025 р.

## РОЗМІРНІ ЕФЕКТИ НАНОТВЕРДОСТІ В СУПЕРІОННИХ КРИСТАЛАХ Cu<sub>6</sub>PS<sub>5</sub>I(Br)

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Досліджені механічні властивості суперіонних кристалів Cu<sub>6</sub>PS<sub>5</sub>I та Cu<sub>6</sub>PS<sub>5</sub>Br методом наноіндентування з неперервним вимірюванням жорсткості контакту (режим CSM) при кімнатній температурі. Дослідження проведені на монокристалах Cu<sub>6</sub>PS<sub>5</sub>I і Cu<sub>6</sub>PS<sub>5</sub>Br, вирощених методом газотранспортних реакцій. Вимірювання нанотвердості Н і модуля Юнга Е проведені на приладі Nano Indenter II (MTS Systems) з алмазним індентором Берковича в імпульсному режимі та режимі із гармонічною модуляцією навантаження на індентор. Параметри кристалів, визначені в імпульсному режимі становили  $H = (3.41 \pm 0.03) \ \Gamma \Pi a$ ,  $E = (80.47 \pm 0.78) \ \Gamma \Pi a$  для  $Cu_6PS_5Br$  і  $H = (3.71 \pm 0.08)$  ГПа,  $E = (90.33 \pm 1.27)$  ГПа для  $Cu_6PS_5I$  Виявлено прямий розмірний ефект індентування (ISE), який пояснений розвитком пластичної деформації та переміщенням дефектів у приконтактній зоні. Розмірний ефект проінтерпретований у рамках теорії градієнтної пластичності деформації (Strain Gradient Plasticity, SGP), яка враховує утворення геометрично необхідних дислокацій під індентором. Визначені параметри моделі:  $H_0 = 4,52 \ \Gamma \Pi a$ ,  $h^* = 83 \ нм$ для  $Cu_6PS_5I$  і  $H_0 = 3,72$   $\Gamma\Pi a$ ,  $h^* = 93$  нм для  $Cu_6PS_5Br$ . Виявлено релаксацію структури кристалів при імпульсному механічному навантаженні. Із апроксимації релаксаційних кривих визначено швидкість пластиної деформації (0,022 нм/с і 0,018 нм/с для  $Cu_6PS_5I$  і  $Cu_6PS_5Br$ ) та часи релаксації ( $\tau = 64$  с і  $\tau = 29$  с для  $Cu_6PS_5I$  і  $Cu_6PS_5Br$ ).

**Ключові слова:** суперіонні кристали; твердіть; модуль Юнга; наноіндентування; теорія градієнтної пластиної деформації.

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